Notice of Allowability		Application No.	Applicant(s)	
		10/734,580	KOMATSU ET AL.	
		Examiner	Art Unit	
	•	Ephrem Alemu	2821	
All claims being allowable, PRO herewith (or previously mailed), NOTICE OF ALLOWABILITY IS	TE of this communication appersection on the MERITS IS a Notice of Allowance (PTOL-85) NOT A GRANT OF PATENT RITHE applicant. See 37 CFR 1.313 sponsive to 8-10-04.	(OR REMAINS) CLOSED in t or other appropriate commun GHTS. This application is sul	his application. If not include ication will be mailed in due o	ed course. THIS
2. X The allowed claim(s) is/a	·			
3. 🔀 The drawings filed on <u>15</u>	December 2003 are accepted by	the Examiner.		
4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)				
<u> </u>	stent Drawing Review (PTO-948) stements (PTO-1449 or PTO/SB/0 5-03, 8-10-04 arding Requirement for Deposit	6. ☐ Interview Sun Paper No./M 8), 7. ☐ Examiner's Al	rmal Patent Application (PTC nmary (PTO-413), ail Date mendment/Comment tatement of Reasons for Allo	·
	Don Wong Cervisory Patent Examiner Fechnology Center 2800			

DETAILED ACTION

Allowable Subject Matter

- 1. Claims 1-5 are allowed.
- 2. The following is an examiner's statement of reasons for allowance: It is agreed that the prior art of record fail to teach or suggest alone or in combination, the limitations: "a second radiator disposed on the surface of the dielectric substrate and in the aperture of the first radiator, and a second ground conductor disposed on the surface of the dielectric substrate and surrounding the second radiator while providing another substantially loop-shaped space between the second radiator and the second ground conductor" as claimed in claim 1. It is for this reason in combination with all the other limitations in the independent claim 1, that claims 1-5 are allowable over prior art of record.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Rao et al. (US 6,597,316); Harrell et al. (US 6,329,950); Walton (US 6,097,345); and Strickland (US 5,952,971); also teach similar inventive subject matter. However the prior art listed above neither teach nor disclose the limitation described above for reason of allowance either alone or in combination.

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Correspondence

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ephrem Alemu whose telephone number is (571) 272-1818. The examiner can normally be reached on M-F Flex hours.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don K Wong can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

EA 1-18-05

Supervisory Patent Examiner
Technology Center 2803